

# Atomic precision advanced manufacturing (APAM) for microelectronics



*PRESENTED BY*

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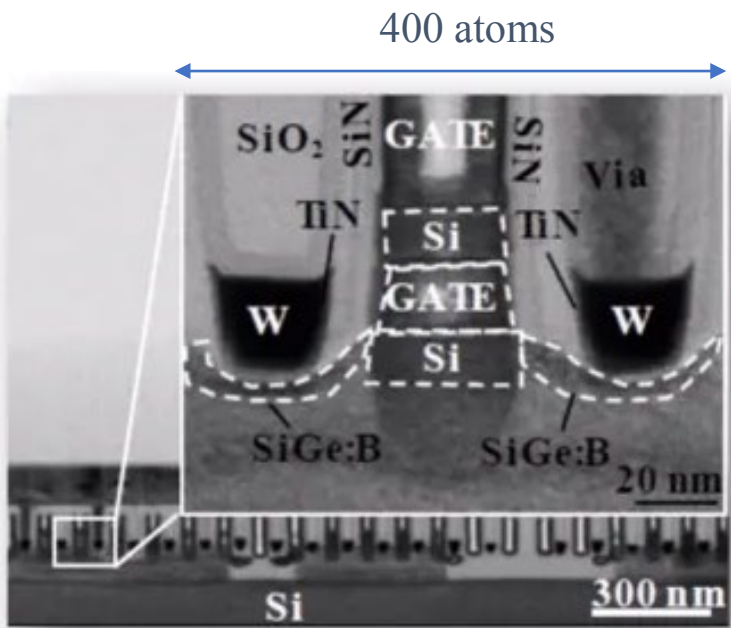


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# Atomic scale commercial opportunity



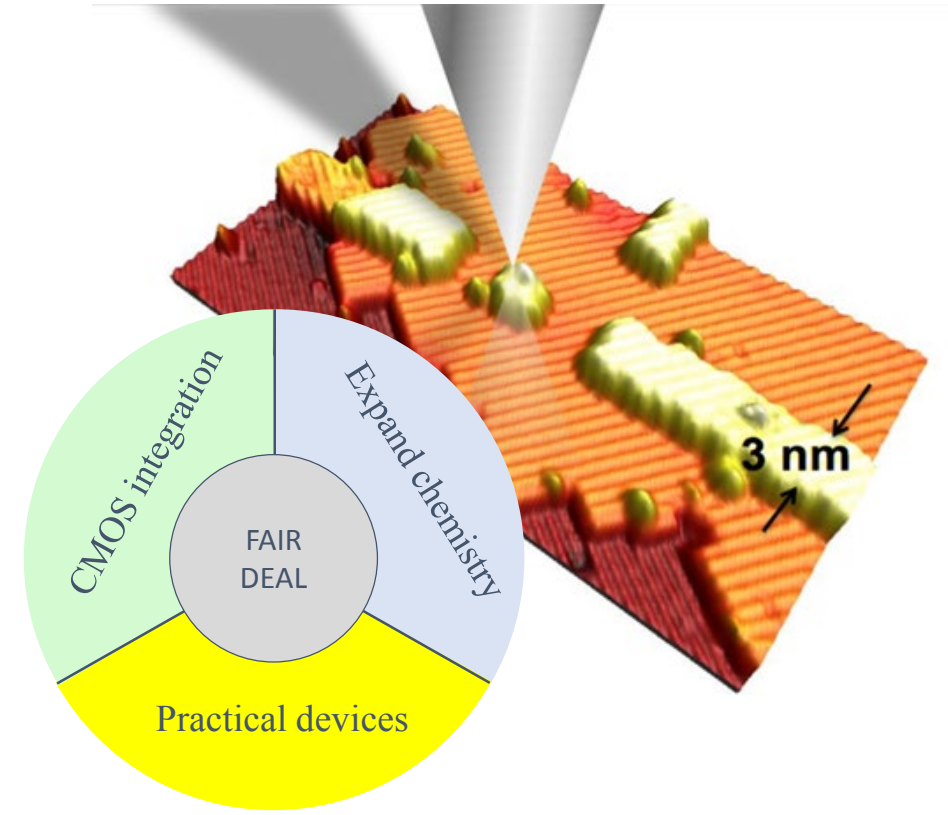
Manufacturing is approaching the atomic scale



Monolithic Approach

S. Subramanian, VLSI 2020

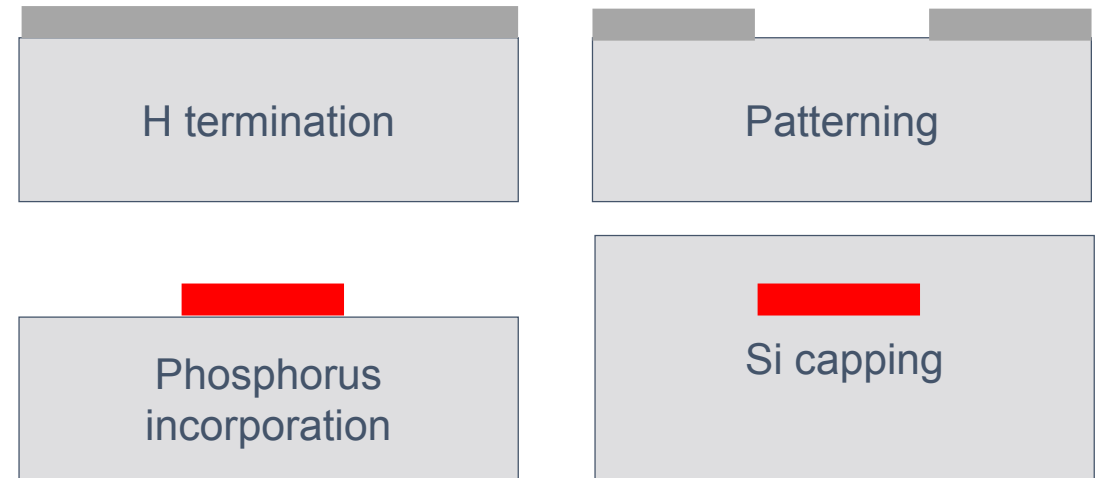
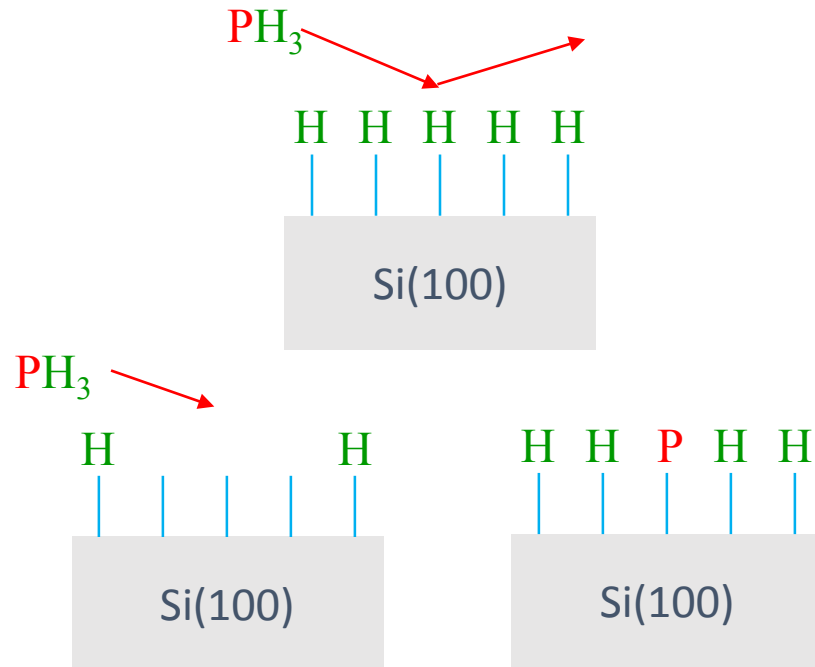
Atomic precision advanced manufacturing (APAM)



Far-reaching Applications, Implications, and Realization of Digital Electronics at the Atomic Limit

APAM lets us explore the device physics & processing limits of the future

# How does APAM work?



## Chemical contrast

Area-selective chemical reaction  
 Single-dopant to atomically abrupt  
 Applied to ALD processes too

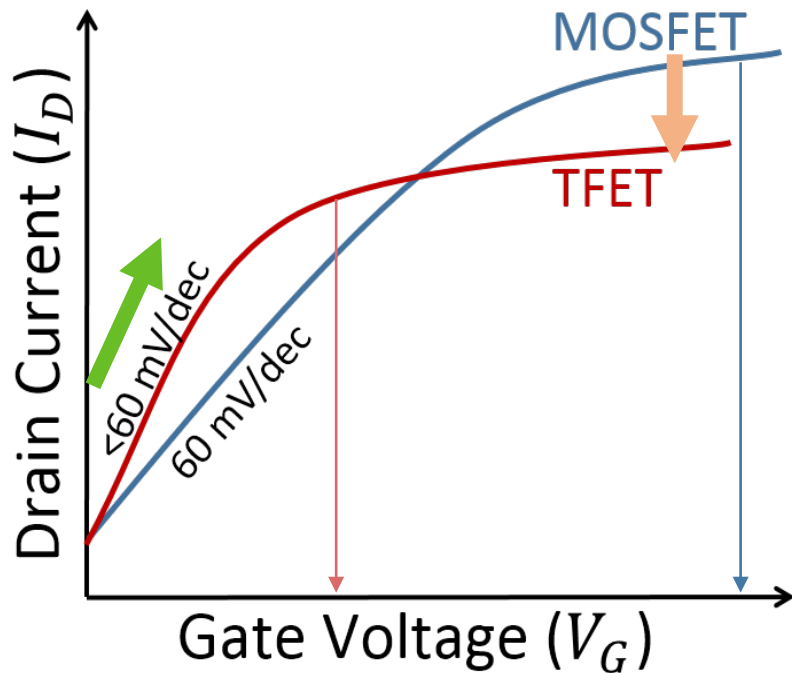
## Non-equilibrium material

Density  $\gg$  solid solubility limit  
 Changes Si electronic structure  
 Confines electrons

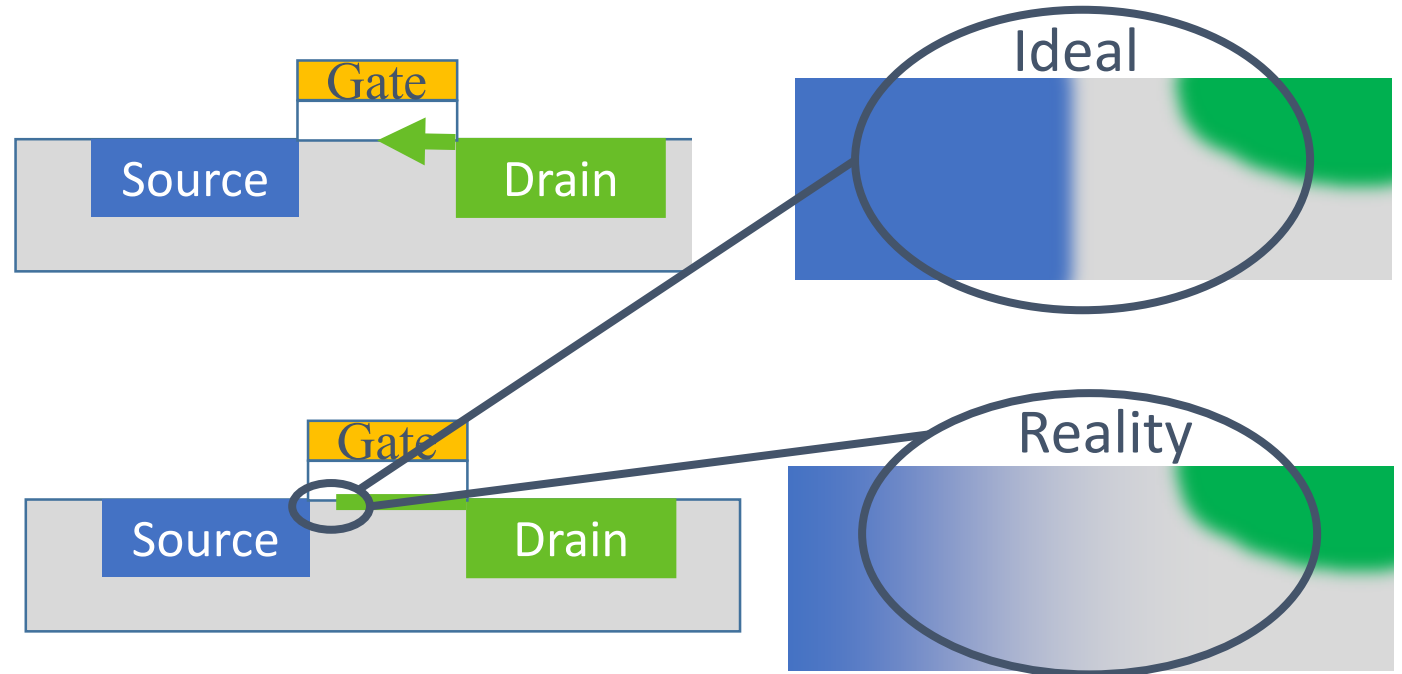
# Tunnel field effect transistors (TFET)



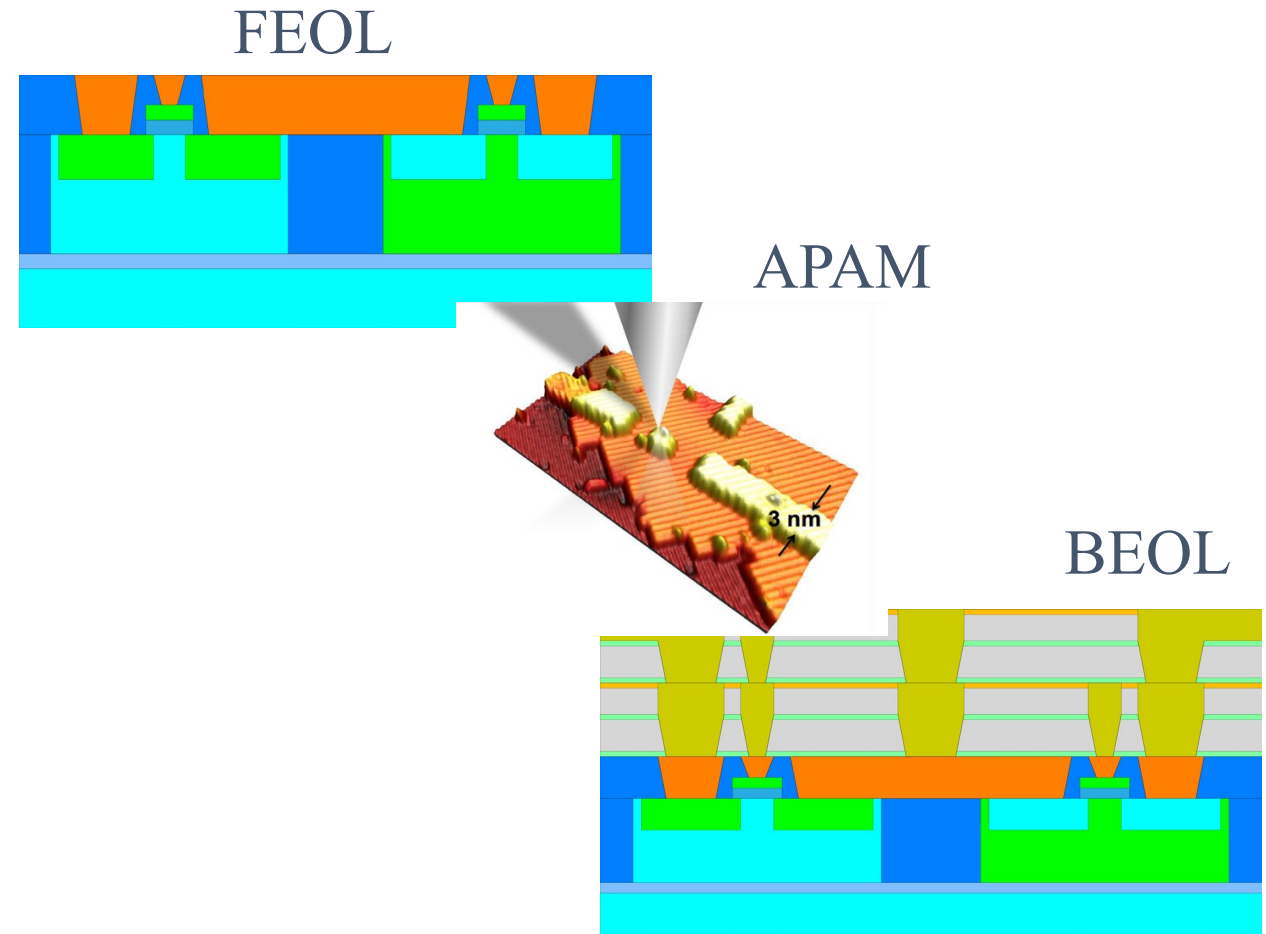
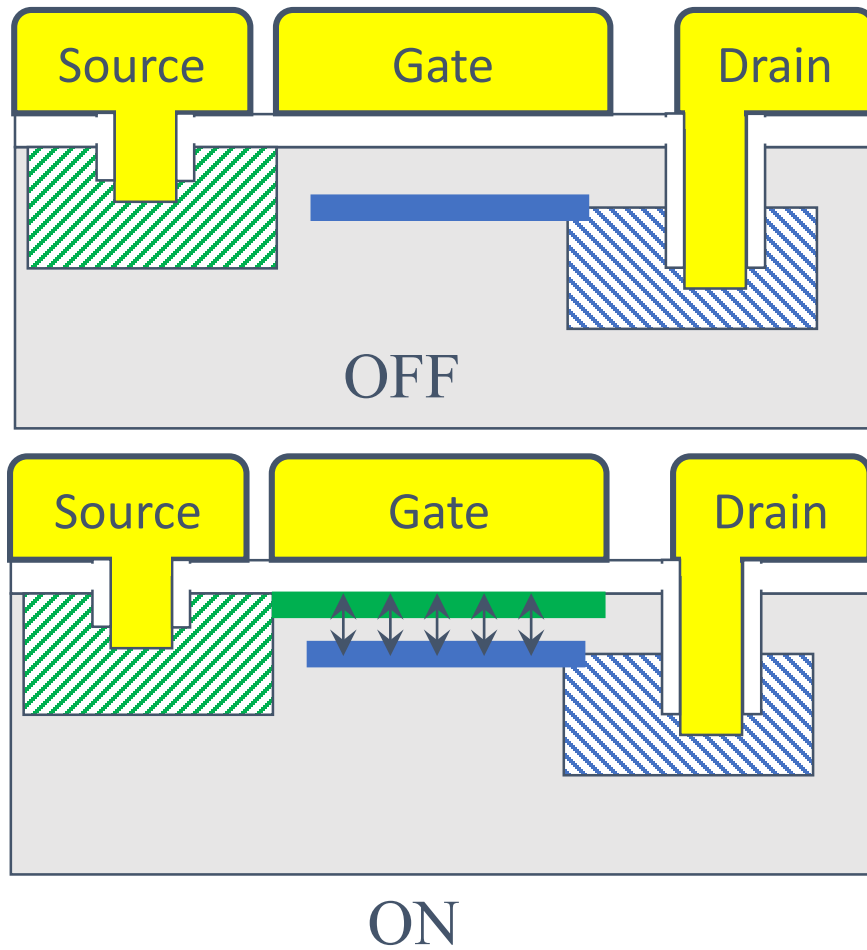
10x improvement in energy efficiency **predicted...**



... but never achieved due to manufacturing limitations



## DOE/AMO project: APAM-enabled vertical TFET



Sharp doping profile: efficient

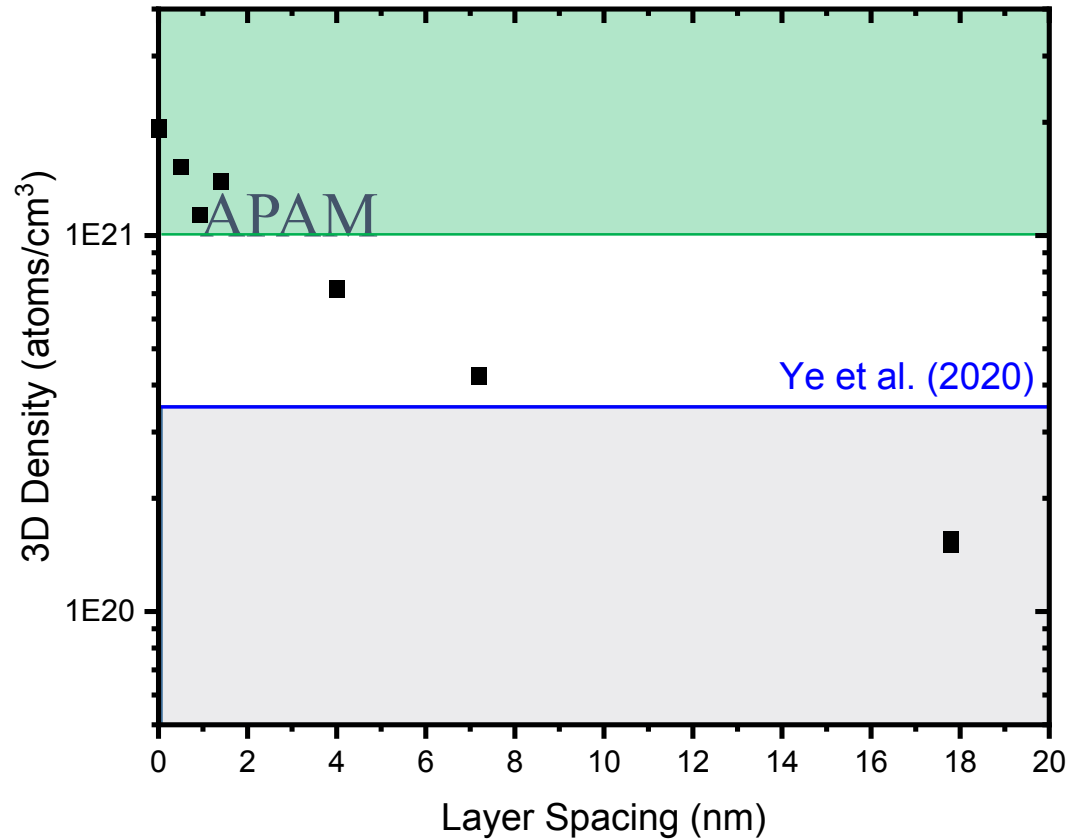
Vertical geometry: large on & small off current

Only requires process integration (done by Sandia), not atomic precision

# Broader impact

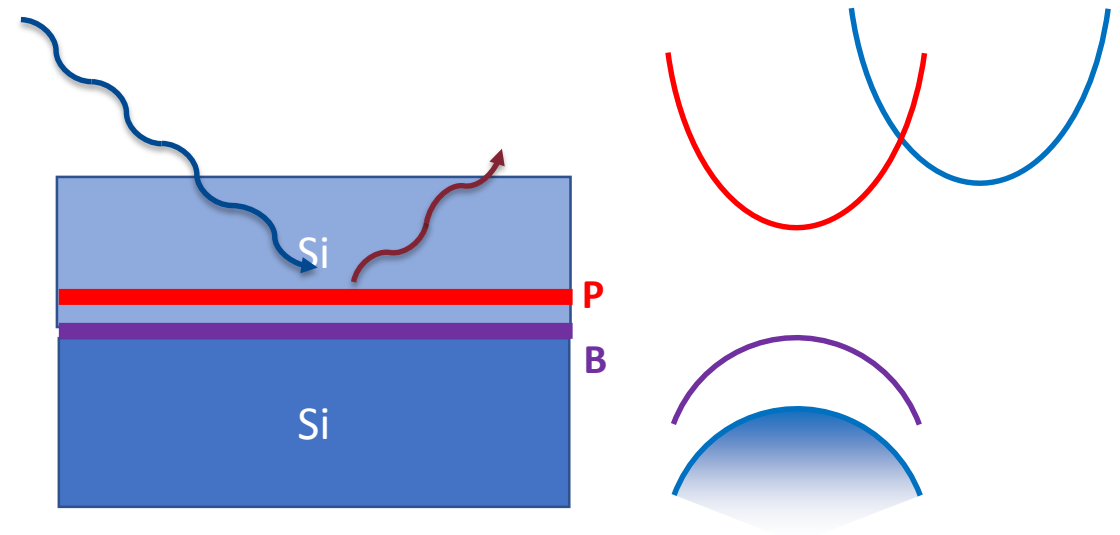


## Manufacturing



Extremely high dopant density for contacts  
(with U Florida and Applied Materials)

## Optically active silicon



P-B bilayer may exhibit direct bandgap  
New knobs to change electronic structure